

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE HOLD, CAN TO CAN TRADE

In re Patent Application of: Joon-Young Yang

Application No.: 09/875,197

Filed: June 7, 2001

Examiner: S. Rao

For: METHOD OF FABRICATING A THIN FILM

TRANSISTOR

## AMENDMENT UNDER 37 CFR 1.116

Box AF Commissioner for Patents Washington, DC 20231

Dear Sir:

In response to the Office Action dated November 6, 2002, finally rejecting claims 21-34, 39 and 40, please amend the above-identified U.S. patent application as follows:

## In the Claims

Please CANCEL Claims 21-34, 39 and 40 without prejudice.

Please ADD the following new claims:

41. (New) A method of fabricating a thin film transistor, comprising:

forming a gate insulating layer on an active layer;

forming a gate on the gate insulating layer;

forming an excited region in an exposed portion of the active layer by implanting hydrogen ions to the active layer by using the gate as a mask; and